

Seminários do Centro de Física

Centro de Física da Universidade do Minho

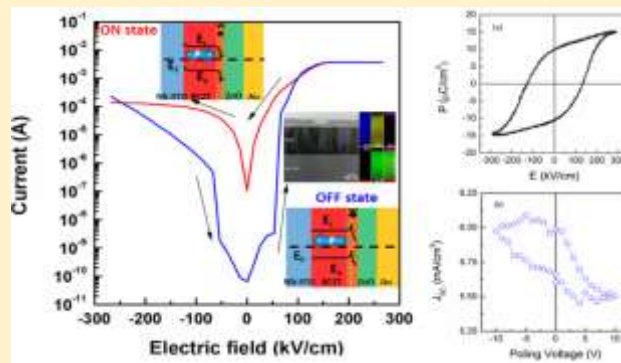
Research line: Functional and smart materials and surfaces for advanced applications

Terça-feira, 27 de Fevereiro de 2018, às 14h30min

Anfiteatro EC1.01 – Campus de Azurém

Ferroelectric based devices for memory and energy applications

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ABSTRACT: Recently, ferroelectric-semiconductor heterostructures have been considered as one of the most potential candidates for next-generation non-volatile memories and photovoltaic (PV) devices. The scientific interest in these heterostructures arises from the charge coupling effect between the ferroelectric and the semiconductor layers, which can enhance the resistive switching (RS) and the PV effects.

In this talk, I will present and discuss the most important achievements obtained in $0.5\text{Ba}(\text{Zr}_{0.2}\text{Ti}_{0.8})\text{O}_3\text{-}0.5(\text{Ba}_{0.7}\text{Ca}_{0.3})\text{TiO}_3$ (0.5BZT-0.5BCT)/ZnO heterostructures for resistive random access memories (RRAMs) and PV devices. An unusual RS behavior is observed in the 0.5BZT-0.5BCT films, where the RS ratio can be 500 times enhanced in the 0.5BZT-0.5BCT/ZnO heterostructures. The RS enhancement is explained by the barrier potential profile modulation of the depletion layer, at the 0.5BZT-0.5BCT/ZnO junction, by the polarization switching of the ferroelectric 0.5BZT-0.5BCT layer.

Moreover, we studied the effect of the position of the ZnO layer on the PV response of the 0.5BZT-0.5BCT/ZnO heterostructure. The enhanced ferroelectric PV effect was achieved for the Pt/ZnO/0.5BZT-0.5BCT/ITO heterostructure with the $J_{sc} \approx 6.1\text{mA}\cdot\text{cm}^{-2}$. The photovoltaic effect is explained in terms of the alignment of the internal electric fields and by the polarization-dependent interfacial coupling effect at the ZnO/0.5BZT-0.5BCT interface, which was confirmed by the presence of a hysteresis loop on the J_{sc} as a function of the poling voltage.

At 15h30min: Meeting : Upgrading of PVD coating systems